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Niklas von Wolff, Joëlle Char, Xavier Frogneux, Thibault Cantat. Synthesis of Aromatic Sulfones from SO₂ and Organosilanes, Under Metal-free Conditions. *Angewandte Chemie International Edition*, 2017, 56, pp.5616-5619. 10.1002/anie.201702311 . cea-01510322

HAL Id: cea-01510322

<https://hal-cea.archives-ouvertes.fr/cea-01510322>

Submitted on 19 Apr 2017

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Synthesis of Aromatic Sulfones from SO₂ and Organosilanes, Under Metal-free Conditions

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Abstract: The conversion of SO₂ to arylsulfones has been achieved for the first time under metal-free conditions, by reacting SO₂ with (hetero)arylsilanes and alkylhalides, in the presence of a fluoride source. The mechanism of this transformation has been elucidated based on DFT calculations, which highlight the influence of SO₂ in promoting C–Si bond cleavage.

The sulfone functional group (RSO₂R') has found widespread applications in organic chemistry, due to its unique physico-chemical properties (stability, lipophilicity, H-bonding etc.),^[1] and many arylsulfone derivatives are currently exploited as drugs (e.g. bicalutamide, eletriptan and Vioxx)^[2] or herbicides. In recent years, heteroarylsulfones were also shown to exhibit important biological activity.^[3] Whereas classical synthesis of sulfones rely on the oxidation of sulfides or the sulfonylation of arenes under harsh conditions,^[4] the introduction of sulfones in pharmaceuticals has called for the development of mild and step efficient methodologies. An alternative route utilizes SO₂ as a sulfonyl cation/anion synthon *via* the formation of an intermediate sulfinic anion that undergoes S-alkylation to yield sulfones (Scheme 1). This strategy has been successfully applied by Willis and coworkers, who were able to generate sulfinic anions from SO₂ surrogates (DABCO-(SO₂)₂ (DABSO), K₂S₂O₅, etc.) with arylmagnesium and aryllithium species.^[5] Using stoichiometric or catalytic quantities of metal compounds, the method has then been extended to milder nucleophiles, such as organo-zinc and organo-boron reagents, to improve the tolerance to functional groups.^[6] For example, arylsulfinates could be obtained from boronic acids, using palladium and gold catalysts.^[7] Because arylboronic acids are compatible with alkylhalides, Shavnya *et al.* demonstrated for the first time, in 2015, the preparation of sulfones in a single step from SO₂ surrogates.^[6b] Interestingly, air and moisture stable organosilanes could also be used for the synthesis of sulfones using a copper(I) oxide as catalyst with SO₂ surrogates and alkylhalides.^[8] In order to circumvent the use of toxic organometallic reagents or metal catalysts, the preparation of sulfones under metal-free conditions is still to be accomplished. In this perspective, we report herein the one-step fluoride mediated synthesis of aryl and heteroarylsulfones from aryl and heteroarylsilanes under metal-free conditions.

Scheme 1. Some representative sulfone-containing drugs and trends in state of the art sulfone synthesis from SO₂.

Organosilanes are very mild nucleophiles and a fluoride source or a base is needed to activate the low polar C–Si bond and facilitate transmetalation to a metal catalyst.^[9] Interestingly, we have recently reported on the fluoride-mediated carboxylation of heteroarylsilanes with CO₂, where CO₂ acts both as a reagent and as a catalyst.^[10] Reasoning that SO₂ is a stronger Lewis acid than CO₂, we have sought to promote the sulfonylation of 2-(trimethylsilyl)pyridine (**1**) with SO₂ adduct DABSO. Addition of DABSO to a CH₂Cl₂ solution of **1** and methyl iodide, in the presence of tetrabutylammonium triphenyldifluorosilicate (TBAT) as a fluoride source, resulted in the formation of the expected methylsulfone **1a** in >90% yield within 17 h at 25 °C (Eq. 1). DABCO, Ph₃SiF, tetrabutylammonium iodide and Me₃SiF were formed as byproducts.

To the best of our knowledge, the conversion of **1** to **2a** represents the first example of the direct sulfonylation of an organosilane reagent under metal-free conditions.

Importantly, **1** selectively reacts with SO₂ and no trace of pyridine or 2-methylpyridine was detected, that would result from quenching of the pyridine anion with protons or MeI, It is notable that, in the absence of SO₂, no conversion of **1** was observed after 17 h at 25 °C, thereby suggesting that SO₂ facilitates the C–Si bond scission.^[11]

Table 1. Synthesis of sulfones by fluoride mediated sulfonylation of 2-(trimethylsilyl)pyridine (**1**) with various electrophiles (Eq. 2).

Entry	RX	Product	Isolated yield [%]
1	CH ₃ I	2a	91
2	C ₂ H ₅ I	2b	88
	C ₆ H ₁₃ I		96
3	C ₆ H ₁₃ Br	2c	83
	C ₆ H ₁₃ Cl		48
4	C ₃ H ₅ I	2d	95
	C ₃ H ₅ Br		83
5	C ₇ H ₇ Br	2e	71
6	C ₃ H ₇ I	2f	64
7	I(CH ₂) ₄ I	2g	78
8	BrCH ₂ COOC ₂ H ₅	2h	77
9	CH ₃ OC ₆ H ₄ COCH ₂ Br	2i	20 (75) ^a

Reaction conditions: $\text{Ar-Si}(\text{Me})_3$ (0.5 mmol), TBAT (0.5 mmol), RX (0.5 mmol), DABSO (0.25 mmol), CH_2Cl_2 (1 mL). a) NMR yield.

As pointed out by Willis *et al.*, DABSO is a practical surrogate for SO_2 , as it is bench-stable and avoids the manipulation of a toxic and corrosive gas.^[12] Nonetheless, **2a** could also be successfully obtained in 71% yield by replacing DABSO with SO_2 gas, highlighting that DABCO does not play an essential role in this transformation. Replacing MeI with other organo-halides, a large variety of 2-pyridylsulfone derivatives were successfully prepared (Eq. 2, Table 1). For example, sulfones **2a-2e** were formed in excellent 71-96% yields using primary alkyl halides such as iodomethane, iodoethane, 1-iodohexane, 1-bromohexane, allyl-iodide and -bromide and benzylbromide respectively (Table 1, entries 1-5). Although TBAT can be easily recycled by addition of TBAF to fluorotriphenylsilane,^[13] the atom efficiency of the present transformation can be improved by utilizing CsF as a fluoride source, in a polar solvent such as CH_3CN . Under these conditions **2e** is isolated in 77% yield (see SI). This reaction is tolerant towards several functional groups such as iodides (**2g**), esters (**2h**), ketones (**2i**) and nitriles (**2j**) (Table 1, entries 7-10). Introducing, an electron donating (3- CH_3 , 5- CH_3 or 6- CH_3) (EDGs) or withdrawing (4- CF_3) (EWGs) group on the pyridine ring of **1** did not influence significantly the reactivity of the organosilane reagent and sulfones **4a-4d** were formed in 64-90% yield, with **4b** (5- CH_3) being the most reactive (Scheme 2).

Scheme 2. Synthesis of (hexylsulfonyl)pyridine. Reaction conditions: $\text{Ar-Si}(\text{Me})_3$ (0.5 mmol), TBAT (0.5 mmol), $\text{C}_6\text{H}_{13}\text{Br}$ (0.5 mmol), DABSO (0.25 mmol), CH_2Cl_2 (1 mL). [a] NMR yield determined with mesitylene as internal standard.

Disappointingly, trimethylphenylsilane (**5**) exhibits no reactivity in the presence of DABSO, EtI and CsF, thereby showing that the pyridine ring has a positive influence on the reaction of **1** with SO_2 . In order to promote the metal-free conversion of arylsilanes to aromatic sulfones, we sought to increase the Lewis acidity of silicon to facilitate the activation of the arylsilane by CsF. The sulfonation of triethoxyphenylsilane (**6a**) with

DABSO, EtI and CsF indeed enables the formation of phenylethylsulfone **7a** after 3 h at 80 °C in a low 5 % yield. This poor conversion could be attributed to the competitive formation of the anion FSO_2^- .^[14] To shift this equilibrium towards the release of the active fluoride and SO_2 sources, the conversion of a variety of aryltriethoxysilanes possessing EDGs and EWGs groups (**6a-6e**) was attempted, with 6 equiv. CsF, 3 equiv. DABSO and 4 equiv. EtI, at 120 °C (Scheme 3). The corresponding arylethylsulfones **7a-7e** were successfully isolated in 33-97% with the electron deficient $\text{C}_6\text{F}_5\text{Si}(\text{OEt})_3$ (**6e**) derivative being the most reactive.

Scheme 3. Synthesis of arylsulfone. Reaction conditions: silane (0.1 mmol), CsF (0.6 mmol), EtI (0.4 mmol), DABSO (0.3 mmol), CH_3CN (1 mL).

The formation of **2a-2j**, **4a-4d** and **7a-7e** represents the first examples of a metal-free synthesis of sulfones from (hetero)arylsilanes. From a mechanistic viewpoint, experiments showed that, in the presence of a fluoride source, the C–Si bond scission of arylsilanes does not take place in the absence of SO_2 . Second, a marked difference in reactivity was observed between pyridyl- and phenyl-silane derivatives, the latter being less reactive. To address these questions, DFT calculations were performed for the sulfonylation of 2-(trimethylsilyl)pyridine (**1**) and trimethylphenylsilane (**5**) with SO_2 , $\text{Me}_3\text{SiF}_2^-$ and MeI (Scheme 4 and SI).

Scheme 4. Computed reaction pathways as calculated by DFT. Level of theory: PBE0/G-D3/ 6-311+G(d) for all atom types / PCM=THF. Values given correspond to Gibbs free energies with respect to the starting material ($\Delta G=0.0 \text{ kcal.mol}^{-1}$). a) fluoride-mediated activation of silanes **1** and **5** in the absence of SO₂. Values given in parenthesis correspond to the conversion of PhSiMe₃ (**5**). b) Proposed mechanism for the metal-free sulfonylation of silanes **1** and **5**. c) Representation of the HOMO in **TS₄** with X = CH (**5**) showing a strong electron delocalization over the SO₂-fragment.

The simplest pathway would rely on a fluoride transfer from the fluoride source to the organosilane and subsequent C–Si bond cleavage of the hypervalent intermediate (**8**) to release the free pyridyl or phenyl anion (Scheme 4a). Nevertheless, this sequence can be discarded as it involves the unstabilized carbanions ($\Delta G > 28.7 \text{ kcal.mol}^{-1}$) and transition states lying at least $35.6 \text{ kcal.mol}^{-1}$ higher than the starting materials. As SO_2 has a positive influence on the early stages of the reaction, its role in the formation of **8** and the activation of the organosilane was investigated computationally (Scheme 4b). SO_2 is a potent electrophile and it readily abstracts a fluoride anion from $\text{Me}_3\text{SiF}_2^-$ to yield the stable FSO_2^- anion, as observed experimentally ($\Delta G = -12.7 \text{ kcal.mol}^{-1}$; $\Delta G^\ddagger(\text{TS}_3) = 6.3 \text{ kcal.mol}^{-1}$). The stable FSO_2^- can then act as a fluoride transfer agent and a transition state (**TS**₄) was located that connects phenylsilane **5** to the sulfinate anion **9**, in the presence of a second molecule of SO_2 . **TS**₄ only lies $20.4 \text{ kcal.mol}^{-1}$ above the starting materials and its low energy is attributed to the strong electrophilic character of SO_2 , able to stabilize the charge build-up on the aryl ring upon cleavage of the C–Si bond. Indeed, the highest occupied molecular orbital (HOMO) of **TS**₄ shows a large delocalization of the carbon lone pair onto the SO_2 fragment, with a minimum structural perturbation of SO_2 ($\text{OSO} = 114.4^\circ$ vs. 117.6° in free SO_2 , mean S–O bond lengths of $1.47 \text{ \AA}$ vs. $1.45 \text{ \AA}$ in free SO_2) (Scheme 4c). The so-formed arylsulfinate anion **9** ($-28.0 \text{ kcal.mol}^{-1}$) could then undergo S-alkylation *via* transition state **TS**₅ ($-11.5 \text{ kcal.mol}^{-1}$) to afford the final sulfone product ($-47.8 \text{ kcal.mol}^{-1}$). This pathway helps rationalize the positive effect of SO_2 in the activation of the organosilane reagent. Nonetheless, it fails to account for the difference in reactivity between **1** and **5**, as similar energy barriers are computed for the two substrates (20.0 vs $20.4 \text{ kcal.mol}^{-1}$).

Reasoning that the nitrogen atom of the pyridyl ring could also interact with SO_2 , the formation of adduct **10** was computed. Interestingly, sulfonylation of **1** leading to **10** is barrier-less and only slightly endergonic ($\Delta G = 12.2 \text{ kcal.mol}^{-1}$). The sulfonylation of the C–Si bond, in the presence of FSO_2^- , then proceeds *via* **TS**₆ to yield sulfinate **11**. Decoordination of SO_2 from **11** is again barrier-free and it releases the expected sulfinate anion **9**. Importantly, **TS**₆ displays similar features to **TS**₄ and the extra stabilization provided by the N– SO_2 interaction translates into a $3.3 \text{ kcal.mol}^{-1}$ stabilization of **TS**₆ compared to **TS**₄. Overall, these mechanistic trends unveil a multiple catalytic influence of SO_2 in the sulfonylation of **1** and **5**. First, SO_2 behaves as an efficient fluoride carrier *via* the reversible formation of FSO_2^- . Second, it facilitates the C–Si bond cleavage of **1** by reversible coordination to the N atom of the pyridine ring. This kinetic behavior is attributed to the electronic and geometric structure of SO_2 . With a bent structure and a low lying π^* vacant orbital perpendicular to the (O,S,O) plane and polarized towards the sulfur atom, SO_2 is poised towards nucleophilic attack. In fact, we computed that the elongation of the S–O bonds does not exceed 9.8% and the bending of the O–S–O angle remains small (9.7%) upon formation of FSO_2^- , **9**, **10** and **11**. These findings suggest that the sulfonylation of other mild nucleophiles could be facilitated by SO_2 , such as the sulfonylation of C–H, N–H or N–Si bonds, under metal-free conditions.

In conclusion, we have shown that sulfones can be accessed under metal-free conditions for the first time from both heteroaryl and arylsilanes, in the presence of SO₂ or a surrogate, the activation of the organosilane being promoted by a fluoride source. Mechanistic investigations show that SO₂ is an excellent electrophile, able to synchronize a fluoride mediated C–Si bond cleavage with C–S bond formation.

Experimental Section

Detailed descriptions of experimental and computational methods are given in the Supporting Information.

Acknowledgements

For financial support of this work, we acknowledge CEA, CNRS, the CHARMMMAT Laboratory of Excellence and the European Research Council (ERC Starting Grant Agreement n.336467). We thank CINES (project c2016086494) for computational time. T.C. thanks the Foundation Louis D. – Institut de France for its support.

Keywords: SO₂ • organosilanes • sulfones • metal-free • DFT calculations

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